

Our Ref. No. 4641-59019
For: METHOD FOR MANUFACTURING RETICLES FOR
CHARGED-PARTICLE-BEAM MICROLITHOGRAPHY
EXHIBITING REDUCED PROXIMITY EFFECTS, AND
RETICLES PRODUCED USING SAME
Express Mail Label No. EL696107254US
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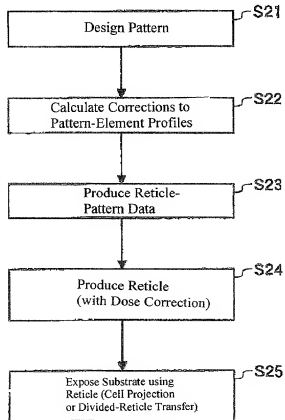


FIG. 1

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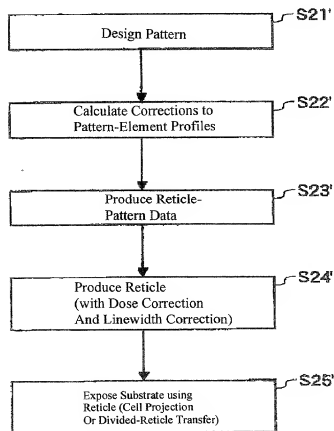


FIG. 2

Donald L. Stephens, Jr.
 Klarquist Sparkman, LLP
 One World Trade Center, Suite 1600
 121 SW Salmon Street
 Portland, Oregon 97204
 Telephone: 503/226-7391

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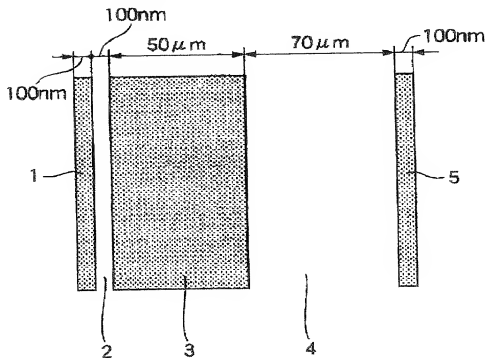


FIG. 3(A)

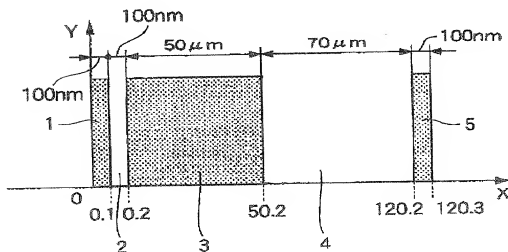


FIG. 3(B)

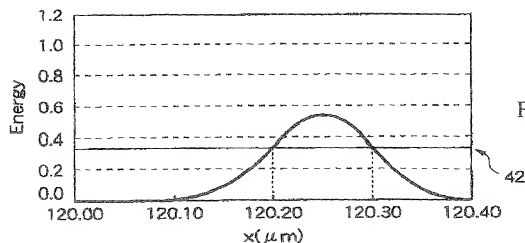
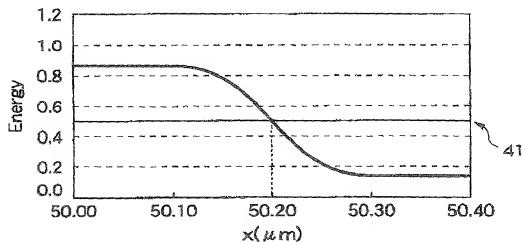
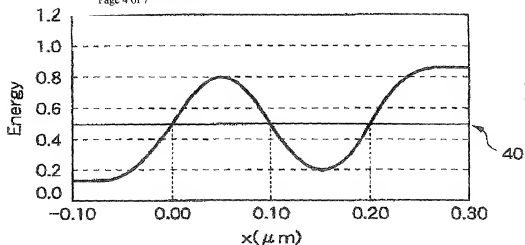
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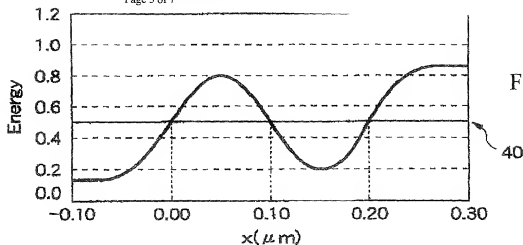


FIG. 5(A)

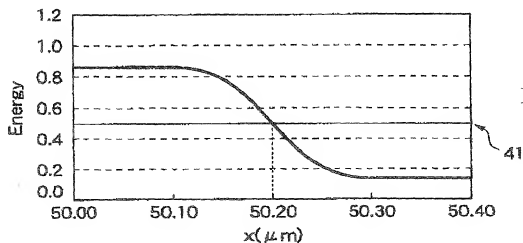


FIG. 5(B)

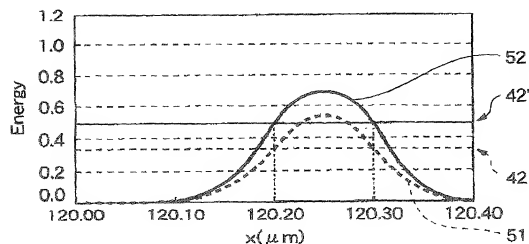


FIG. 5(C)

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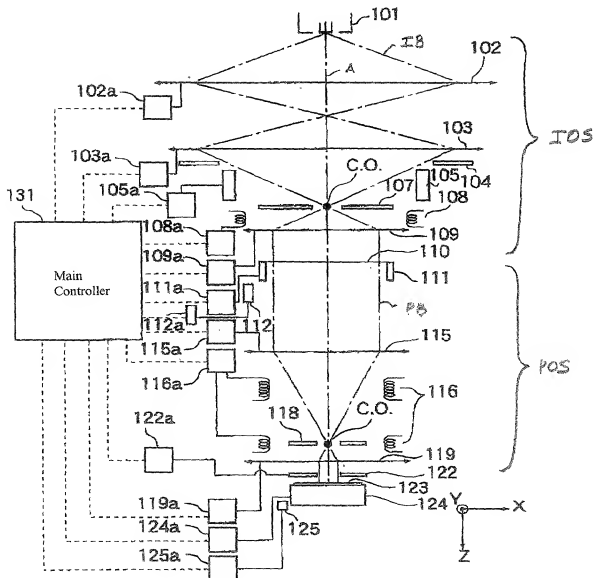


FIG. 6

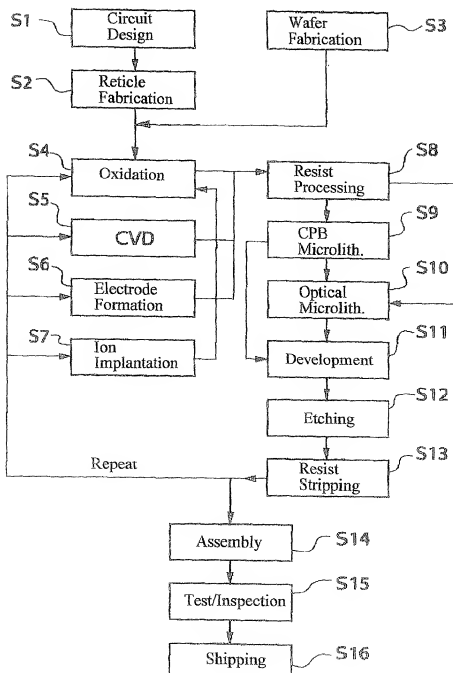


FIG. 7